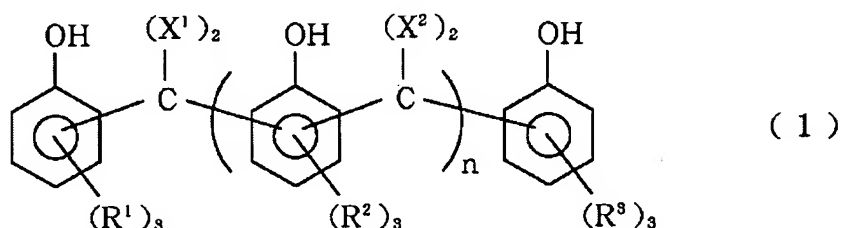


IN THE CLAIMS:

Please amend the claims as shown below.

1. (Currently Amended) A field effect transistor comprising at least a substrate, an organic semiconductor layer, an insulating layer, and a conductive layer, wherein the insulating layer comprises a cured product of a phenol resin represented by a following general formula (1):



~~(wherein;~~ wherein  $R^1, R^2$  and  $R^3$  are each independently at least one selected from the group consisting of hydrogen atom, halogen atom, hydroxymethyl group, alkyl group having 1 to 12 carbon atoms, alkenyl group, alkynyl group, alkoxyl group, alkylthio group, and alkyl ester group,  $X^1$  and  $X^2$  are each independently at least one selected from the group consisting of hydrogen atom, alkyl group having 1 to 12 carbon atoms, alkenyl group, alkynyl group, and aryl group, and  $n$  is an integer of 0 to ~~2,000~~ 2,000.

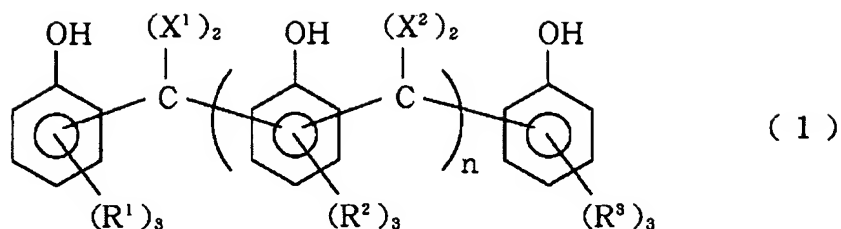
2. (Original) The field effect transistor according to claim 1, wherein the conductive layer comprises a gate electrode, a source electrode, and a drain electrode, the insulating layer includes a gate insulating layer, and the gate insulating layer is a cured product of a phenol resin represented by the above general formula (1).

3. (Original) The field effect transistor according to claim 2, wherein the thickness of the gate insulating layer is 100 nm to 1 $\mu$ m.

4. (Original) The field effect transistor according to any one of claims 1 to 3, wherein part or all of the conductive layer comprises an agglomerate of conductive fine particles having a primary particle diameter of 5 nm to 2 $\mu$ m.

5. (Currently Amended) A process for producing a field effect transistor comprising a substrate, an organic semiconductor layer, an insulating layer, and a conductive layer, the process comprising the steps of:

coating a thermosetting resin composition containing at least a phenol resin represented by the following general formula (1):



(~~wherein, wherein~~ wherein  $R^1$ ,  $R^2$  and  $R^3$  are each independently at least one selected from the group consisting of hydrogen atom, halogen atom, hydroxymethyl group, alkyl group having 1 to 12 carbon atoms, alkenyl group, alkynyl group, alkoxyl group, alkylthio group, and alkyl ester group,  $X^1$  and  $X^2$  are each independently at least one selected from the group consisting of hydrogen atom, alkyl group having 1 to 12 carbon atoms, alkenyl group, alkynyl group, and aryl group, and  $n$  is an integer of 0 to ~~2,000~~ and 2000; and heating ~~[[it]]~~ the thermosetting resin to form the insulating layer.

6. (Original) The process for producing a field effect transistor according to claim 5, wherein part or all of the conductive layer is formed by applying a solution, dispersion, or paste of a conductive material or a precursor of the conductive material and heating it.

7. (Original) The process for producing a field effect transistor according to claim 5, wherein the softening point of the phenol resin contained in the thermosetting resin composition is in the range of 70 to 130°C.